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基于H₂/O₂等离子体和钛硅沸石的丙烯气相环氧化方法

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摘要: 将H₂/O₂非平衡等离子体现场产生的气态H₂O₂和丙烯与耦合反应器中钛硅沸石TS-1直接接触,实现了丙烯气相环氧化反应.结果表明,非平衡等离子体生成气态H₂O₂的速率由介质阻挡放电的输入功率决定,环氧丙烷的生成速率和选择性取决于 钛硅沸石催化剂和反应条件.在H₂和O₂进料流量分别为170和8ml/min,介质阻挡放电输入功率为3.5W,环氧化反应温度为 110°C,丙烯进料量为18ml/min,催化剂用量为0.8g的条件下,生成环氧丙烷产率达246.9g/(kg·h)、环氧丙烷选择性和H₂O₂有效 利用率分别为95.4%和36.1%,反应36h内未见催化剂失活.

关键词:等离子体;过氧化氢;钛硅分子筛;气相丙烯环氧化;环氧丙烷

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Gas Phase Epoxidation of Propylene with TS-1 and in Situ H₂O₂ Produced by a H₂/O₂ Plasma

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Abstract: Gas phase epoxidation of propylene was performed by directly contacting propylene and gaseous H_2O_2 on the surface of TS-1 catalyst in an integrated reactor. The gaseous H_2O_2 was produced in situ by a H_2/O_2 plasma. The H_2O_2 formation rate can be enhanced by increasing the power density of the H_2/O_2 plasma reactor. The yield and selectivity for propylene oxide (PO) can be increased by optimizing the reaction conditions and using suitable TS-1 catalysts. With a power injection of 3.5 W, flow rates of H_2 , O_2 , and propylene of 170, 8, and 18 ml/min, respectively, catalyst loading of 0.8 g, and epoxidation temperature of 110 °C, the yield and selectivity for PO and the utilization rate of H_2O_2 were 246.9 g/(kg·h), 95.4%, and 36.1%, respectively. During the gas phase reaction, no decline of TS-1 activity was observed. **Key words:** plasma; hydrogen peroxide; titanium silicalite-1; gas-phase epoxidation of propylene oxide

环氧丙烷 (PO) 是重要的基本有机化工中间体. 目前, PO 生产方法主要有氯醇法和共氧化法, 然而 这两种方法分别存在环境污染和联产品等问题, 所 以自 20 世纪 80 年代以来, 人们一直致力于开发以 H₂O₂为氧化剂、钛硅沸石 (TS-1)为催化剂的丙烯环 氧化技术^[1,2]. 目前, 基于 H₂O₂和 TS-1 的丙烯液相环 氧化技术已在比利时、韩国和泰国等地工业化^[3]. 但 该技术尚存在原料 H₂O₂成本昂贵和溶剂甲醇使用 量过多等问题^[4,5].

近年来, Haruta 等^[6~9]以及 Cumaranatunge 等^[10] 以负载 Au 的含 Ti 材料 (TiO₂, TS-1, Ti-MCM-41 和 Ti-MCM-48) 为催化剂, H₂和 O₂ 为原料原位获得活 性氧物种 (一般认为与 H₂O₂有关),并在不使用任何 溶剂的条件下进行丙烯气相环氧化反应.最近, Klemm 等^[11]以气化的工业 H₂O₂为原料,采用微通道 反应器技术研究了 TS-1 催化剂上丙烯直接气相环

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氧化反应. 上述方法因不使用溶剂,工艺十分简单, 同时以H₂和O₂为起始原料还可克服直接使用工业 H₂O₂带来的成本问题. 但是,用微反应器合成大宗化 学品实用性不大. 目前在负载 Au 催化剂上原位产生 环氧化活性氧物种的效率还非常低^[4].

我们在H₂/O₂非平衡等离子体直接合成H₂O₂的 研究基础上^[12],建立了一种新的丙烯气相环氧化方 法,如图1所示.该法采用等离子体和钛硅沸石固定 床耦合反应器,即反应器上段是自冷式介质阻挡放 电反应器(适宜工作温度范围是 2~30 °C),用于将 H₂-O₂混合气在常温常压下直接转化为H₂O₂^[13];下 段是装填TS-1的固定床反应器(常压,适宜工作温 度范围 50~200 °C),这样上段产生的H₂O₂在此进行 丙烯环氧化反应.可见,H₂O₂合成和丙烯气相环氧化 分段进行,便于优化各自反应条件,另外用非平衡等 离子体直接合成H₂O₂不仅选择性和产率高,而且不



H₂, O₂, H₂O, propylene, PO, etc.

图 1 丙烯气相环氧化耦合反应器示意图

Fig. 1. Integrated reactor for gas-phase epoxidation of propylene. 1—High voltage electrode; 2—DBD (dielectric barrier discharge) plasma chamber; 3—Grounding electrode; 4—Circulating cooling water; 5—Electric heater. PO— Propylene oxide.

需气化,可直接用于气相环氧化反应.

本文采用两种自合成的 TS-1 催化剂,其中 TS-1¹按文献[14]合成,晶粒度约为 150 nm, Si/Ti 比为 33; TS-1²按文献[15]合成,晶粒度为 5~10 µm, Si/Ti 比为 150. X射线粉末衍射 (XRD)、漫反射紫外-可见 吸收光谱 (UV-Vis) 以及骨架振动红外吸收光谱 (FT-IR)等表征结果表明,所用 TS-1样品均属于典型 的 MFI 结构,且基本不含非骨架 Ti. 环氧化反应在上 述耦合反应器中进行,产物用两个串联的 GC 7890 型气相色谱仪 (分别使用 TCD 检测器 和 FID 检测器) 在线分析.

表1为在耦合反应器中进行丙烯气相环氧化反 应结果.由表可见,当介质阻挡放电输入功率从2.4 W提高到3.5W时,H2O2时空产率由2.1g/(L·h)增至 5.7 g/(L·h); 相应地 PO 产率由 62.9 g/(kg·h) 增至 157.3 g/(kg·h),但H2O2有效利用率略有下降,这可能与丙 烯和H2O2的比例变化有关.保持输入功率不变,即 H₂O₂产率不变, 当反应温度从 50 ℃ 提高到 110 ℃, PO 产率由 80.4 g/(kg·h) 增至 157.3 g/(kg·h), H₂O₂有 效利用率也由11.7%提高到23.0%. 当反应温度升至 140 °C 时, PO 产率下降到 150.3 g/(kg·h), 且 PO 选择 性和H₂O₂有效利用率均有所下降.当以TS-1²代替 TS-1¹时,在相同反应条件下,PO产率可达246.9 g/(kg·h), 明显优于 Cumaranatunge 等^[10]和 Huang 等^[7] 报道的气相环氧化最好结果(分别为134和137 g/(kg·h)). 另外,本文气相环氧化生成PO选择性较高, 一般超过95%(副产物主要有CO2、乙醛、丙醛、丙 酮、丙烯醛和丙二醇等).这可能与等离子体合成的 H₂O₂纯度高和避免因使用溶剂而发生副反应等因 素有关.

综上可见,非平衡等离子体生成气态H2O2的速

表1 氢气、氧气和丙烯在介质阻挡放电等离子体和TS-1固定床耦合反应器中气相环氧化结果 Table 1 Gas-phase enoxidation of hydrogen oxygen and propylene in an integrated reactor composed of DBD plasma and TS-1 fixed bed units

Tuble 1 Sub phase opportation of hydrogen, and propyrole in an integrated reactor composed of DDD phasma and 10 1 meet ord anno						
PI (W)	$Y_{\rm H2O2}/(g/(L\cdot h))$	Catalyst	<i>T</i> /⁰C	$Y_{\rm PO}/({\rm g}/({\rm kg}\cdot{\rm h}))$	S _{PO} /%	U _{H2O2} /%
2.4	2.1	TS-1 ¹	110	62.9	95.5	24.2
3.0	3.7	TS-1 ¹	110	104.9	95.5	23.7
3.5	5.7	TS-1 ¹	110	157.3	95.6	23.0
3.5	5.7	TS-1 ¹	50	80.4	96.5	11.7
3.5	5.7	TS-1 ¹	80	122.3	96.6	17.9
3.5	5.7	TS-1 ¹	140	150.3	92.2	21.9
3.5	5.7	TS-1 ²	110	246.9	95.4	36.1

PI-Power injected into the H2/O2 DBD plasma chamber.

 $U_{\rm H2O2}$ = (PO produced in TS-1 bed)/(H₂O₂ produced in DBD plasma chamber), in molar unit.

率由介质阻挡放电输入功率决定,而 PO 的生成速 率、选择性以及H₂O₂有效利用率则取决于 TS-1 本身 性质和反应温度.

能否在不使用溶剂和反应温度较高的气相环氧 化反应条件下尽可能提高H2O2有效利用率,是该领 域的主要挑战.为了研究H₂O₂在TS-1催化剂上的分 解规律,本文设计了预吸附H2O2的TS-1样品吹扫实 验,具体过程为:首先在室温用 30% H₂O₂溶液浸泡 TS-1¹样品,经抽滤得到含H₂O₂的TS-1¹湿样品,然后 在与气相环氧化相似的进料条件(H₂/C₃=170/18)下, 于不同温度吹扫TS-1¹湿样品,同时用四级质谱检测 吹扫尾气中的 O₂和 PO 浓度变化. 所得结果见图 2. 由图可见,在50℃的较低温度下,用含丙烯的气体 吹扫样品时就有PO生成,同时H2O2分解生成O2.随 着吹扫温度的提高, O2和PO的瞬时最大浓度逐渐增 加. 这说明H₂O₂的分解和环氧化是一对竞争反应, 且均随温度的升高而加快.还可以看出,当吹扫温度 低于80°C时,提高吹扫温度相对有利于PO生成;而 当吹扫温度高于80℃时(如110℃),提高吹扫温度 则对生成O₂相对有利.这说明选取适当温度可提高 H₂O₂的有效利用率.由表1也可见,在耦合反应器中 进行的气相环氧化反应中确实存在环氧化反应的最 佳温度,为110℃,高于图2中得出的适宜温度.这可 能是由于吹扫实验中TS-1样品微孔内凝聚了大量 液体H2O2,在吹扫过程中其与丙烯接触机会少而更 易发生分解. 总之,选择适宜的环氧化反应温度能够



图 2 用含丙烯气体在不同温度吹扫预吸附 H₂O₂的 TS-1¹ 样品时在线质谱监测结果

Fig. 2. On-line MS analysis of the vent gas when a propyl-ene-containing gas flowed over $TS\text{-}1^1$ adsorbed with $H_2O_2.$

提高H₂O₂的有效利用率.

据文献[6,16]报道,在负载型Au催化剂上发生 的气相环氧化反应失活很快,这被认为是具有双齿 结构的烯烃氧化物种强吸附在含 Ti 载体的 Ti-O-Ti 结构上所致. 在本文中, 当耦合反应器中环氧化反应 温度为50℃时,2h后就出现失活,经调变反应温度 (未示出)发现,这是由于反应过程中生成的水润湿 了催化剂表面,堵塞了其孔道所致.在80℃以上进 行环氧化反应可以避免这种失活. 图3为在110℃下 环氧化反应稳定性实验结果.可以看出,反应36h内, 环氧化反应未见失活. PO 产率和选择性以及 H₂O₂ 有效利用率分别维持在 246.9 g/(kg·h), 95.4% 和 36.1% 左右. 这可能有两方面原因: (1) 本文采用的 TS-1 催化剂中 Ti 原子基本上都是以孤立的骨架 Ti 形式存在,基本不含Ti-O-Ti结构的非骨架钛物种, 因而可避免由双齿结构的丙烯氧化物种强吸附引起 的结焦失活:(2)本文所用的气态过氧化氢在较高的 环氧化温度下可能具有自清洁作用^[17],即H₂O₂的氧 化可能及时清除了催化剂表面的强吸附物种,从而 避免了催化剂结焦失活.



图 3 在耦合反应器中进行的丙烯环氧化反应的稳定性 Fig. 3. Stability of the propylene epoxidation conducted in the integrated reactor.

综上所述,本文提出了一种以H₂、O₂和丙烯为 原料的丙烯气相环氧化制备 PO 的新方法. 它利用 H₂/O₂等离子体现场合成H₂O₂,提高了H₂O₂的生成 效率,避免了负载Au催化剂制备困难等问题. 同时, 现场生成的H₂O₂是气态,不用气化即可直接用于反 应,简化了反应流程. 在优化反应条件的基础上制备 适合于气相环氧化反应的TS-1催化剂,可望解决过 氧化氢利用率低等问题.

参考文献

- 1 Clerici M G, Bellussi G, Romano U. J Catal, 1991, 129: 159
- 2 成卫国, 王祥生, 李钢, 郭新闻, 催化学报 (Cheng W G, Wang X Sh, Li G, Guo X W. Chin J Catal), 2004, **25**: 513
- 3 蔡杰, 吴丽娜, 中国氯碱 (Cai J, Wu L N. China Chlor-Alkali), 2009, (5): 1
- 4 Nijhuis T A, Makkee M, Moulijn J A, Weckhuysen B M. Ind Eng Chem Res, 2006, 45: 3447
- 5 Danciu T, Beckman E J, Hancu D, Cochran R N, Grey R, Hajnik D M, Jewson J. *Angew Chem*, *Int Ed*, 2003, **42**: 1140
- 6 Hayashi T, Tanaka K, Haruta M. J Catal, 1998, 178: 566
- 7 Huang J H, Taker T, Akita T, Ohashi H, Haruta M. Appl Catal B, 2010, **95**: 430
- 8 Uphade B S, Yamada Y, Akita T, Nakamura T, Haruta M. *Appl Catal A*, 2001, **215**: 137
- 9 Uphade B S, Akita T, Nakamura T, Haruta M. *J Catal*, 2002, 209: 331
- 10 Cumaranatunge L, Delgass W N. J Catal, 2005, 232: 38
- 11 Klemm E, Dietzsch E, Schwarz T, Kruppa T, de Oliveira A L, Becker F, Markowz G, Schirrmeister S, Schütte R, Caspary K J, Schüth F, Hönicke D. *Ind Eng Chem Res*, 2008, 47: 2086
- 12 Zhou J C, Guo H C, Wang X S, Guo M X, Zhao J L, Chen L X, Gong W M. Chem Commun, 2005: 1631
- 13 郭洪臣,周军成,王祥生,郭明星,赵剑利,宫为民(Guo H Ch, Zhou J Ch, Wang X Sh, Guo M X, Zhao J L, Gong W M). CN 1 546 368. 2004
- 14 Taramasso M, Perego G, Notari B. US 4 410 501. 1983
- 15 Li G, Guo X W, Wang X Sh, Zhao Q, Bao X H, Han X W, Lin L W. *Appl Catal A*, 1999, **185**: 11
- 16 Mul G, Zwijnenburg A, Vander Linden B, Makkee M, Moulijn J A. J Catal, 2001, 201: 128
- 17 Liu X W, Wang X Sh, Guo X W, Li G, Yan H Sh. Catal Lett, 2004, 97: 223

英译文 English Text

Propylene oxide (PO) is an important intermediate for the production of a variety of chemicals. Commercially, PO is produced by the chlorohydrin process and hydroperoxide process. These commercial processes face the problems of by-product management and co-product marketing. The development of alternative processes that solve one or more of these issues is ongoing. The epoxidation of propylene with dilute H_2O_2 is a highly desired green chemistry reaction for PO production [1,2]. Currently, this process (HPPO) has been commercialized in Belgium, Korea, and Thailand [3]. Compared with conventional PO process technologies, the HPPO process offers the benefits of economics, environmental friendliness, and opportunities for future growth.

However, the high H_2O_2 cost (production and transportation) and solvent problems (PO solvolysis, mass transfer issue, reactants diffusion control) [4,5] are the Achilles heel of this process.

In recent years, Haruta et al. [6–9] and Cumaranatunge et al. [10] have studied the gas phase generation of PO from hydrogen, oxygen, and propylene over TiO₂, TS-1, Ti-MCM-41, and Ti-MCM-48 supported gold (Au) catalysts. Most recently, Klemm et al. [11] have reported the gas phase epoxidation of propylene with vaporized H_2O_2 in a microreactor. These gas phase epoxidation methods do not have the problem of a solvent. At the same time, the generation of H_2O_2 in situ from H_2 and O_2 offers the chance to lower the cost of H_2O_2 . However, the low H_2O_2 (or hydroperoxide species) generation efficiency on metallic sites [4] and difficulty of the scale-up of microreactors are disadvantages of these gas phase epoxidation methods.

We had previously shown that high concentration gaseous H_2O_2 can be continuously generated by the reaction of a H_2/O_2 non-equilibrium plasma [12]. In this work, gas phase epoxidation of propylene was studied by directly contacting plasma generated gaseous H_2O_2 and propylene on the surface of a TS-1 catalyst. The investigation was carried out in a tubular Pyrex reactor which consisted of two tightly coupled reaction units (Fig. 1). The DBD plasma unit was used for H_2O_2 synthesis [13], and the fixed-bed unit, which was loaded with the TS-1 catalyst, was used for epoxidation. The most important feature of this integration was the utilization of gaseous H_2O_2 , produced by the DBD plasma selectively and efficiently, for PO production.

The TS-1 samples (particle sizes of TS-1¹ and TS-1² were 150 nm and 5–10 μ m, respectively; Si/Ti ratios were 33 and 150, respectively) used were synthesized according to literature [14,15]. The insertion of Ti atoms into the silicalite framework of these samples was confirmed by XRD and FT-IR spectroscopy. Non-framework Ti species were below the detection of the UV-Vis technique. The products of the epoxidation of propylene with gaseous H₂O₂ were determined by two online gas chromatographs (GC 7890, equipped with TCD and FID detector, respectively) in series.

The gas phase epoxidation results (Table 1) of O_2 , H_2 and propylene in the integrated reactor showed that a high PO yield can be achieved by: (1) increasing the power injection (PI), (2) optimizing the reaction temperature, and (3) choosing a suitable TS-1 catalyst. High PI can increase the H_2O_2 formation rate in the H_2/O_2 DBD plasma unit, which was a major advantage in this study. The TS-1 catalyst was very important in determining PO yield and H_2O_2 utilization. As shown in Table 1, under optimum reaction conditions (PI = 3.5 W, 110 °C), H_2O_2 utilization was improved to 36.1% over the TS-1² catalyst. Meantime, PO yield was greatly improved to 246.9 g/(kg·h), which was much higher than the best results of 134 and 137 g/(kg·h) reported by Cumaranatunge et al. [10] and Huang et al. [7], respectively. More importantly, the PO selectivity in this study was generally maintained at over 95%. We believe that the gas phase epoxidation of propylene with high purity plasma gaseous H_2O_2 avoids the formation of many byproducts. Side reactions were promoted when solvent and commercial H_2O_2 (contains acidic stabilizer) were used.

H₂O₂ utilization is an important issue in the gas phase epoxidation process with an O2 and H2 mixture because it affects the economics of this method. The reduction of H_2O_2 decomposition is the key to improving H₂O₂ utilization. In order to investigate the effects of reaction temperature on H₂O₂ decomposition and epoxidation, a simulated epoxidation experiment was carried out. Online MS was used to analyze in real time the concentration changes of O₂ and PO in the vent gas when a propylene-containing gas $(H_2/C_3 =$ 170/18) was flowed over TS-1¹ pre-adsorbed with H₂O₂. The samples of TS-1¹ pre-adsorbed with H₂O₂ were prepared by the impregnation-filtration method. Figure 2 shows that a lower reaction temperature (below 80 °C) favored epoxidation, and a higher temperature (above 80 $^{\circ}$ C) favored H₂O₂ decomposition. This implied that a relatively mild reaction temperature favored H₂O₂ utilization. However, the epoxidation of propylene and decomposition of H₂O₂ are competitive reactions over a broad temperature range. Attempts to improve H₂O₂ utilization in epoxidation by simply adjusting the reaction temperature will be inefficient. The simulated epoxidation experiment suggested that a suitable temperature was 80 °C. However, the fixed-bed reaction (Table 1) suggested that the best epoxidation reaction temperature should be 110 °C. The discrepancy may be due to the different state of H₂O₂ in simulated epoxidation and gas phase epoxidation. The capillary condensation of liquid H₂O₂ in the channels of TS-1 make the decomposition much easier

at a higher temperature. Table 1 indicates that the choosing of a suitable TS-1 catalyst can solve low $\rm H_2O_2$ utilization.

Figure 3 shows the stability of gas phase propylene epoxidation conducted in the integrated reactor during a 36 h operation. No deactivation was observed. This result is longer than the catalyst life (< 10 h) of a Au/TiO₂ catalyst in the gas phase epoxidation in the presence of H_2 , O_2 and propylene. The yield and selectivity for PO were maintained at 246.9 g/(kg·h) and 95.4%, respectively. H₂O₂ utilization was maintained at 36.1%. We believe that the excellent stability of gas phase epoxidation of propylene and gaseous H_2O_2 can be attributed to both the TS-1 catalyst and the self-cleaning effect of H₂O₂. First, the TS-1² sample has high crystallinity and was free of Ti-O-Ti species. According to literature reports [6,16], on a Ti-O-Ti containing titania support, strongly adsorbed species, carbonates/carboxylates were easily formed that resulted in the deactivation of the epoxidation catalyst. On the other hand, coking deactivation can be prevented by cleaning the strongly adsorbed coking precursors with H₂O₂. This function of H₂O₂ can be inferred from the previous works of regenerating a spent TS-1 catalyst by H₂O₂ oxidation [17].

In summary, this study proposed a novel epoxidation method using H_2 , O_2 , and propylene. Compared with previous epoxidation methods, the advantages of this method are: better H_2O_2 formation rate from the use of the DBD plasma H_2O_2 -synthesizing technique, a simpler technological process by directly using gaseous H_2O_2 in propylene epoxidation, and simple catalyst preparation with the use of only TS-1 catalysts. Future research will focus on the preparation of a more suitable TS-1 catalyst for the gas phase epoxidation of propylene.

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